				Сотр	lete if Known
	INFORMATION	21221	001105	Application Number	10/722 647
STATEMENT BY APPLICANT (use as many sheets as necessary)				Filing Date	
				First Named Inventor	Chih-Yuan HSIAO
(use as many sneets as necessary)				Art Unit	2822
				Examiner Name	
Sheet	1	of	ì	Attorney Docket Number	10113231

•	U.S. PATENT DOCUMENTS				
Examiner Initials	Cite No.	Document Number (Number – kind code)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Passages or Relevant Figures Appear
mer	A1	US 6,432,774 B2	08/13/2002	Heo et al	
mg	A2	5,519,236	05/21/1996	Ozaki	
	А3				
	A4				
	A5				
	A6				
	A7				

FOREIGN PATENT DOCUMENTS						
Examiner Initials	Cite No.	Document Number (Number – kind code)	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines Where Passages or Relevant Figures Appear	Т
	B1					
	B2					
	В3				1	
	B4					

OTHER PRIOR ART						
Examiner Initials	Cite No.	Include name of author (in CAPS), 'title of article' (when appropriate), title of the item (book, magazine, symposium, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published	Т			
MT	C1	DEBRA S. WOOLSEY, 'Enhanced discrete DMOS power trench gate oxide growth', Solid State Technology, Volume 45, Issue 8, August 2002, Pennwell Publishing, US				
	C2					
	СЗ		İ			
	C4					
	C5					

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